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## Tuning the electronic structure of monolayer graphene/MoS<sub>2</sub> van der Waals heterostructures via interlayer twist

Wencan Jin,<sup>1</sup> Po-Chun Yeh,<sup>1</sup> Nader Zaki,<sup>1</sup> Daniel Chenet,<sup>1</sup> Ghidewon Arefe,<sup>1</sup> Yufeng Hao,<sup>1</sup> Alessandro Sala,<sup>2</sup>

Tevfik Onur Mentes,<sup>2</sup> Jerry I. Dadap,<sup>1</sup> Andrea Locatelli,<sup>2</sup> James Hone,<sup>1</sup> and Richard M. Osgood, Jr.<sup>1,\*</sup>

<sup>1</sup>Columbia University, New York, New York 10027, USA

<sup>2</sup>Elettra-Sincrotrone Trieste S.C.p.A., I-34012 Basovizza, Trieste, Italy

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We directly measure the electronic structure of twisted graphene/MoS<sub>2</sub> van der Waals heterostructures, in which both graphene and MoS<sub>2</sub> are monolayers. We use cathode lens microscopy and microprobe angle-resolved photoemission spectroscopy measurements to image the surface, determine twist angle, and map the electronic structure of these artificial heterostructures. For monolayer graphene on monolayer MoS<sub>2</sub>, the resulting band structure reveals the absence of hybridization between the graphene and MoS<sub>2</sub> electronic states. Further, the graphene-derived electronic structure in the heterostructures remains essentially intact, irrespective of the twist angle between the two materials. In contrast, however, the electronic structure associated with the MoS<sub>2</sub> layer is found to be *twist-angle dependent*; in particular, the *relative* difference in the energy of the valence band maximum at  $\overline{\Gamma}$  and  $\overline{K}$  of the MoS<sub>2</sub> layer varies from approximately 0 to 0.2 eV. Our results suggest that monolayer MoS<sub>2</sub> *within the heterostructure* becomes predominantly an indirect band-gap system for all twist angles except in the proximity of 30°. This result enables potential band-gap engineering in van der Waals heterostructures comprised of monolayer structures.

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The interest in two-dimensional (2D) materials and materials physics has grown dramatically over the past decade. The family of 2D materials, which includes graphene (Gr), transition-metal dichalcogenides (TMDCs), hexagonal boron nitride, etc., can be fabricated into atomically thin films since the intralayer bonding arises from their strong covalent character, while the interlayer interaction is mediated by weak van der Waals forces. In addition to homogenous 2D materials, van der Waals (vdW) heterostructures [1] have recently emerged as a novel class of materials, in which different 2D atomic planes are vertically stacked to give rise to distinctive properties and exhibit new structural, chemical, and electronic phenomena [2-8]. These artificial heterostructures, in contrast with traditional heterostructures, can be designed and assembled by stacking individual 2D layers without lattice parameter constraints. The weak electron coupling at the interface of vdW heterostructures offers the possibility of combining the intrinsic electronic properties of the individual 2D layers. In particular, Gr/MoS<sub>2</sub> vdW heterostructures are remarkable because of the high carrier mobility [9] and broadband absorption [10] of graphene, as well as the direct band gap [11-13] and extremely strong light-matter interactions [14] of monolayer  $MoS_2$ . The combination of these unusual characteristics has led to potential applications in field-effect transistor devices [15,16], energy harvesting materials [17,18], and memory cells [19,20]. Despite this weak coupling, however, there is also the possibility of engendering emergent properties that are distinct from that of their constituent materials as has been observed in TMDC, e.g., the direct-to-indirect gap transition in going from monolayer to multilayer crystals. In fact, for the Gr/MoS<sub>2</sub> interface, density functional theory (DFT) calculations have predicted the crossover between a direct and indirect band gap of MoS<sub>2</sub> induced by the modification of interlayer orientation [21,22]. Thus, changing the relative orientation of the constituent gapless and direct-gapped 2D monolayers forming the heterostructure, results in the tunability of its electronic structure. This tunability is of pervasive importance to the development of new high performance electronic devices. Also, the significant quenching photoluminescence peak intensity in Gr/TMDC heterostructures suggests a charge transfer between the Gr and TMDC layer [18,23]. These theoretical and optical investigations have led to a pressing need for a full understanding of the electronic structure of Gr/MoS<sub>2</sub> vdW heterostructures. Very recently, photoemission measurements of the Gr/MoS<sub>2</sub> interface have been attempted [24-26]. Thus Coy-Diaz et al. examined a twisted interface between polycrystalline graphene and a bulk MoS<sub>2</sub> crystal [24,25], while Miwa et al. examined the electronic structure of a multidomain epitaxial MoS<sub>2</sub>-graphene heterostructure, which is laterally averaged over different orientations [26]. In all, a direct experimental investigation of the evolution of the momentum-resolved electronic structure with twist angle in Gr/MoS<sub>2</sub> twisted bilayer has, thus far, been lacking.

In this Rapid Communication, we report direct measurement of the twist-angle dependence of the local electronic structure of Gr/MoS<sub>2</sub> vdW heterostructures supported on a Si substrate with native oxide. In order to characterize our samples, we employed a range of methods based on synchrotronbased cathode lens microscopy, warranting high sensitivity to both the crystal and electronic structure. An important finding, using microprobe low-energy electron diffraction ( $\mu$ -LEED) line profile analysis, is that the corrugation of the graphene overlayer on MoS<sub>2</sub> is less than that of graphene on SiO<sub>2</sub>. Selected-area angle-resolved photoemission spectroscopy ( $\mu$ -ARPES) measurements show that the Dirac point is consistently located within experimental error at the Fermi level and that the Fermi velocity is close to that of pristine

<sup>\*</sup>Corresponding author: osgood@columbia.edu

graphene, thus indicating that graphene remains essentially intact when placed on monolayer MoS<sub>2</sub> regardless of twist angle. The ARPES band maps of MoS<sub>2</sub> show the absence of band hybridization with Gr bands for occupied states within 2.5 eV of the valence band maximum (VBM), but do show a dependence of the relative energy positions of the VBM at  $\bar{K}$ and  $\bar{\Gamma}$  on twist angle. Perhaps most significantly, our results suggest that monolayer MoS<sub>2</sub> within the heterostructure is predominantly an indirect band-gap system for all twist angles except at or near the twist angle of 30°.

Our measurements were performed on the spectroscopic photoemission and low-energy electron microscopy (SPELEEM) in operation at the Nanospectroscopy beamline at the Elettra Synchrotron in Trieste, Italy [27,28]. The  $\mu$ -LEED measurements were restricted to regions of 1 and 0.5  $\mu$ m in diameter. The  $\mu$ -ARPES measurements were carried out with an energy resolution of 250 meV, at incident photon energy of 26 eV (see Supplementary Section 1 of this paper [29] and Ref. [30]).

Figure 1(a) shows the photoemission process and its configuration. The incident photon beam makes a 16° grazing angle with respect to the sample, leading to preferential probing of states derived from out-of-plane orbitals. We fabricated our samples by subsequent transfer of chemical vapor deposition (CVD) grown monolayer Gr [31] and CVD-grown monolayer  $MoS_2$  [32] onto an *n*-doped Si(100) substrate with a nativeoxide surface layer. As indicated in Ref. [32], this type of CVD-grown MoS<sub>2</sub> was carefully characterized using TEM, Raman, and photoluminescence, and was confirmed to be a uniform monolayer except for small multilayer patches in the center of the island. Due to the growth process, the Gr and MoS<sub>2</sub> domains are randomly rotated by a certain twist angle  $(\theta)$ . Accordingly, the reciprocal space structures [Fig. 1(b)] are rotated by the same angle. This fact allows us to use  $\mu$ -LEED to determine the twist angle. In Fig. 1(c), the stack shows the  $\mu$ -LEED images of Gr over MoS<sub>2</sub> with a finite twist angle. Using a 40 eV incident electron beam, we obtain

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the diffraction pattern of the Gr overlayer and from which we see a sixfold-symmetry structure, as shown in the top plane of the stack. For the middle plane of the stack, on the other hand, an electron energy of 45 eV is used, for which the  $\mu$ -LEED pattern is from an exposed region of the bottom MoS<sub>2</sub> layer. Using 2D Gaussian fitting, we were able to determine the centers of the diffraction spots, which are denoted by colored circles in the LEED pattern. By projecting the two hexagonal spot arrays for Gr (red) and MoS<sub>2</sub> (blue) to the bottom plane of the stack, we obtain the twist angle  $\theta$ . Besides LEED measurements, twist-angle determination was carried out using ARPES constant energy maps (Supplemental Material Fig. S3), which revealed agreement between these two methods.

LEED I-V measurements (tuning the incident electron beam energy from 20 to 100 eV) do not show evidence of any moiré structure, or spots arising from multiple scattering between the Gr and  $MoS_2$  lattices, indicating a weak superlattice potential and lack of long-range coherence. While the ability to see a moiré structure can be hindered by spot broadening in LEED, we also do not see evidence of a superlattice potential in the ARPES measurements (discussed below), thus supporting the above claim.

Our previous work has shown that the width of the LEED (00) spot can be used as a signature of the corrugation of 2D materials [33,34]. This approach to linewidth analysis has been used with the present LEED I-V measurements as well (see Supplementary Section 4 of this paper). These measurements show that Gr on MoS<sub>2</sub> has a linewidth-derived angle variation of  $4.1^{\circ} \pm 0.4^{\circ}$ , which is less than the value of  $6.1^{\circ} \pm 0.5^{\circ}$  found in the case of graphene on SiO<sub>2</sub> [33]. This suggests that Gr on MoS<sub>2</sub> is less corrugated than on the widely used SiO<sub>2</sub> substrate.

After characterizing the crystal quality, we measured the electronic structure of the heterostructures using the ARPES capability of the SPELEEM system. Figure 2(a) shows the constant-energy map (CEM) of a graphene overlayer



FIG. 1. (Color online) (a) Schematic of the photoemission process and configuration. (b) Brillouin zone (BZ) of Gr and surface Brillouin zone (SBZ) of MoS<sub>2</sub> with a twist angle of  $\theta$ . We define the high-symmetry points of Gr BZ (red) as  $M-\Gamma-K$  and those of MoS<sub>2</sub> SBZ (blue) as  $\overline{M}-\overline{\Gamma}-\overline{K}$ . (c) LEED patterns (upper plane) derived mostly from the graphene overlayer at 40 eV, and LEED pattern (middle plane) derived mostly from the MoS<sub>2</sub> bottom layer at 45 eV. The diffraction spots are projected to the bottom plane to extract the twist angle.



FIG. 2. (Color online) (a) Constant energy map of a graphene overlayer heterostructure at a binding energy of 875 meV. (b) ARPES band map (left) and second-derivative-intensity plot (right) of the graphene-derived Dirac cone along the  $\Gamma$ -*K* direction. (a) and (b) are acquired from the Gr overlayer with a twist angle of 19° with respect to the MoS<sub>2</sub> bottom layer. (c), (d) ARPES band map and corresponding second-derivative-intensity plot of a Gr overlayer with a twist angle of 12° and 28°, respectively.

heterostructure at a binding energy of 875 meV. The contour is from the spectrum of the graphene-derived Dirac cones. Figure 2(b) shows the ARPES band map and the corresponding second-derivative-intensity plot [35] of the graphene-derived Dirac cone along the  $\Gamma$ -K direction. Note that there are no replica cones near the K or K' points, which is also evidence for the absence of a moiré structure. Figures 2(a) and 2(b) are acquired from the Gr overlayer with a twist angle of 19° with respect to the MoS<sub>2</sub> bottom layer. The anisotropy of the spectral intensity in the CEM as well as in the ARPES band map is due to the photoemission selection rules [36]. From the data in Fig. 2(b), we determine that the Dirac point resides in close vicinity of the Fermi level at the K point (the Dirac point is determined using momentum distribution curves (MDCs) fitting, and the Fermi level is determined using Fermi-function fitting; see Supplemental Material Fig. S5). By fitting the band dispersion with a straight line, we obtain a Fermi velocity of  $(0.99 \pm 0.01) \times 10^6$  m/s, which is close to the value of pristine graphene [37]. We also investigated the band structure of Gr overlayer heterostructures for different twist angles. Figures 2(c) and 2(d) show the ARPES band map and the corresponding second-derivative-intensity plot of Gr with a twist angle of 12° and 28°, respectively, and the Fermi velocities that we extract for these two cases are  $(0.96 \pm 0.02) \times 10^6$  m/s and  $(0.97 \pm 0.02) \times 10^6$  m/s, respectively. Thus, within our energy and momentum resolution, we do not see significant electronic-structure changes of the graphene-derived bands with twist angle. Therefore, the electronic structure of monolayer graphene is essentially intrinsic when it is an overlayer on  $MoS_2$ , regardless of the twist angle. Based on the LEED intensity profile linewidth analysis and the ARPES band map, we conclude that monolayer  $MoS_2$  is an ideal substrate for preserving the intrinsic properties of monolayer graphene.

It is known that the alignment of the energy bands at the interface significantly affects the behavior of semiconductor heterostructures [38]. ARPES allows us to obtain the band alignment between the Gr-derived bands and the  $MoS_2$ -derived bands directly. Thus, we find that for all our measured twist angles, Gr-derived bands are very close to intrinsic and that the Gr-derived Dirac point is situated within the  $MoS_2$  band gap (Supplemental Material Fig. S6).

In Ref. [24], the ultraviolet photoemission spectroscopy measurement of Gr capped bulk MoS<sub>2</sub> (with one particular relative rotation of 12°) shows a ~0.1 eV VBM shift in comparison with a bare bulk MoS<sub>2</sub> crystal, which hints at an electronic structure modification of MoS<sub>2</sub> in a Gr/MoS<sub>2</sub> interface. We thus measure the electronic band structure derived from the MoS<sub>2</sub> bottom layer in the Gr/MoS<sub>2</sub> heterostructure. Figures 3(a)–3(d) show the ARPES band maps along  $\overline{M}$ - $\overline{\Gamma}$  -  $\overline{K}$ of the MoS<sub>2</sub> SBZ for twist angles of 5°, 12°, 19°, and 28°,



FIG. 3. (Color online) (a)–(d) ARPES band map along  $\overline{M}$ - $\overline{\Gamma}$ - $\overline{K}$  of the MoS<sub>2</sub> layer with a twist angle of 5°, 12°, 19°, and 28°, respectively. The green dashed curves are a Gr-derived band in heterostructures acquired from a tight-binding model. (e)–(h) Second-derivative plot of the uppermost valence band in (a)–(d).

respectively. Besides MoS2-derived bands, we also observe the overlay of Gr-derived bands. To make a comparison, we use a nearest-neighbor tight-binding (NNTB) model [37] to generate the band dispersion of intrinsic monolayer Gr and superimpose these bands (green dashed curves) for specific twist angles onto the corresponding ARPES band maps. As shown in Figs. 3(a)-3(d), the measured graphene-derived bands agree well with the NNTB bands of intrinsic graphene. Note that for all measured twist angles, there is no indication of band hybridization for Gr in the range of binding energies measured in this study, which is in good agreement with theoretical predictions [22]. In the corresponding MDC plot and secondderivative plot, we can confirm the absence of hybridization (Supplemental Material Fig. S7). Another set of ARPES measurements of a molecular beam epitaxy grown MoSe<sub>2</sub> thin film, which was formed on a bilayer of graphene/SiC, also showed no evidence of band hybridization between the MoSe<sub>2</sub> and graphene electronic states [39]. However, a recent ARPES study of CVD-grown graphene on a bulk MoS<sub>2</sub> crystal shows modification of the graphene  $\pi$  bands by way of hybridization with bulk MoS<sub>2</sub> bands, mostly at higher binding energies than measured here [25]. Presumably, the increase in the number of states with out-of-plane character, as is the case for *bulk*  $MoS_2$ , increases the possibility for hybridization in comparison to our case of monolayer MoS<sub>2</sub>.

Figures 3(e)-3(h) show the corresponding secondderivative intensity plots of the uppermost valence band derived from MoS<sub>2</sub> as shown in Figs. 3(a)-3(d). The intensity of the signal is strong in the  $\overline{\Gamma M}$  direction but weak in the  $\overline{\Gamma K}$  direction due to photoemission selection rules. The  $\overline{\Gamma M}$  region is dominated by out-of plane Mo  $d_{(z^2)}$  orbitals, while, in the vicinity of the  $\overline{K}$  point, it is derived mainly from the in-plane Mo  $d_{(x^2-y^2)}/d_{xy}$  orbitals [40]. In Fig. 3(h)  $(\theta = 28^{\circ})$ , we find that the VBM at  $\bar{K}$  and  $\bar{\Gamma}$  are almost degenerate. However, for smaller twist angles and as shown in Figs. 3(e)–3(g), the VBM at  $\bar{K}$  is lower than that at  $\bar{\Gamma}$ . These results indicate that the relative position of the VBM of  $\bar{\Gamma}$  and  $\bar{K}$  is tuned by the twist angle. For comparison, we also have measured the heterostructure, in which MoS<sub>2</sub> is the overlayer (i.e., MoS<sub>2</sub>/Gr where MoS<sub>2</sub> is on top) for the case of a 12° twist angle (Supplemental Material Fig. S8). Note that the energy difference between the VBM of  $\bar{\Gamma}$  and  $\bar{K}$  in this MoS<sub>2</sub>/Gr heterostructure (0.13 ± 0.03 eV) at this twist angle is almost identical to that of the Gr/MoS<sub>2</sub> heterostructure (0.12 ± 0.03 eV) with the same twist angle, and both are close to the VBM shift (~0.1 eV) in a Gr/bulk MoS<sub>2</sub> interface [24].

In Fig. 4, we show the evolution of energy difference between the VBM of  $\overline{\Gamma}$  and  $\overline{K}$  with twist angle. The energy difference between the VBM of  $\overline{\Gamma}$  and  $\overline{K}$  is determined by using the energy distribution curve (EDC) peak fitting method (Supplemental Material Fig. S9). The red dashed line is a guide to the eye to illustrate the overall trend in the data. We find that the energy difference appears to decrease gradually from ~0.2 to ~0 eV as the twist angle evolves from 5° to 28°. Thus, our results suggest that monolayer MoS<sub>2</sub> within the heterostructure is predominantly an indirect band-gap system for all twist angles except at or near the twist angle of 30°.

A detailed theoretical investigation is beyond the scope of this experimental paper; we thus discuss the physical origin of the electronic structure modification in  $Gr/MoS_2$ vdW heterostructures in light of theoretical works already in the literature. In the first, Ebnonnasir *et al.* found that the tunable band structure of a  $Gr/MoS_2$  heterostructure arises from twist-angle-dependent strain, and specifically discussed



FIG. 4. (Color online) Energy difference between  $\overline{\Gamma}$  and  $\overline{K}$  versus twist angle in the Gr/MoS<sub>2</sub> (purple) and MoS<sub>2</sub>/Gr (green) heterostructures.

two extreme cases,  $0^{\circ}$  and  $30^{\circ}$  [21]. For a  $0^{\circ}$  twist angle, charge loss affects the Mo-S bond length; for a  $30^{\circ}$  twist angle, on the other hand, it is predicted that charge loss of the Mo-S bond is absent because graphene has a different registry with respect to the S atoms for this orientation [21]. Note that comprehensive DFT calculations have shown that band structure of monolayer MoS<sub>2</sub> is significantly affected by bond length variation [41]. Similarly, Wang *et al.* attribute the twist-angle dependence of the MoS<sub>2</sub> band structure to strain, and they too mention the presence of charge redistribution at the interface [22]. Note, however, that these two predictions for the trend in the direct-to-indirect band-gap transition with twist angle differ qualitatively; the reason for this difference between these two theory reports is beyond the scope of this paper.

Our measurements show a trend in the direct-to-indirect band gap that is similar to that predicted by Ebnonnasir *et al.*, except that the angle assignment is reversed to that of their report; our  $\overline{\Gamma}$ - $\overline{K}$  trend is plotted in Fig. 4. While the reason for this inconsistency is not clear, note that these DFT calculations mentioned above assumed commensurability between Gr and  $MoS_2$ , which may not exactly be the case in experiment. Also, we note the presence of the *n*-doped Si substrate in our experiment which is not taken into account in either of the theoretical reports; the effect of the Si substrate on  $MoS_2$ , however, is expected to be weak based on a previous report [11,13].

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An important question is why a dramatic Fermi-level shift in Gr was not observed given that there may be charge transfer at the interface between MoS<sub>2</sub> and Gr. Quantitatively, the charge transfer amount in Ref. [22] is  $\sim 10^{-4}$  electron per carbon (e/C). The position of the Fermi level of Gr can be estimated using  $E_F \cong v_F \sqrt{|n|}$  [37], where  $v_F$  is the Fermi velocity, and *n* is the carrier concentration in Gr. A charge transfer of  $10^{-4}$  e/C gives a  $\sim 60$  meV Fermi-level shift which is smaller than our energy resolution. Thus, in summary, the negligible Fermi-level shift in Gr, observed here, is explainable by a modest charge transfer from MoS<sub>2</sub> to Gr.

In conclusion, our experiments have enabled us to directly measure the electronic structure of Gr/MoS<sub>2</sub> vdW heterostructures with different twist angles. We find that the Gr layer behaves as pristine graphene when transferred atop monolayer MoS<sub>2</sub> regardless of twist angle, and its Dirac point is situated within the band gap of  $MoS_2$ . In contrast, the electronic structure associated with the MoS<sub>2</sub> shows obvious twist-angle dependence, specifically a VBM shift between  $\overline{\Gamma}$  and  $\overline{K}$ , a phenomenon that appears, as a result of calculations, to be a result of charge-transfer-induced strain. Our results further reveal a sufficiently weak superlattice potential between the Gr and MoS<sub>2</sub> layers, and that the Gr layer is relatively flat on top of the MoS<sub>2</sub>, in contrast to a Gr/SiO<sub>2</sub> system. This work opens up one possible route to new designer heterostructures, which combine the relativistic Dirac fermions in monolayer Gr with the twist-angle-tuned band gap in monolayer TMDCs.

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- [29] See Supplemental Material at http://link.aps.org/supplemental/ 10.1103/PhysRevB.92.201409 for atomic photoionization cross section; bright- and dark-field LEEM image of Gr/MoS<sub>2</sub>; determination of twist angle with ARPES; determination of the mosaic spread of Gr/MoS<sub>2</sub>; determination of the doping level of Gr using MDCs fitting; alignment of graphene  $\pi$  bands and MoS<sub>2</sub> bands; absence of band hybridization confirmed by MDCs and second-derivative plot; electronic structure of MoS<sub>2</sub>/Gr heterostructure; determination of the energy difference between VBMs using EDC peak fitting.
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